$\approx$  3.2) is essentially the same as that in W<sub>2</sub>Me<sub>8</sub><sup>4-</sup>, we can enter a point for the latter on Sattelberger and Fackler's plot of the  $\delta \rightarrow \delta^*$  transition energy vs. M-M distance.<sup>25</sup> As shown in Figure 3, the new point lies very close to the straight line previously established using the Cr, Mo, and Re compounds.

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# Methyl and Fluorine Substituent Effects on the Gas-Phase Lewis Acidities of Silanes by Ion Cyclotron Resonance Spectroscopy

## M. K. Murphy and J. L. Beauchamp\*1

Contribution No. 5406 from the Arthur Amos Noyes Laboratory of Chemical Physics, California Institute of Technology, Pasadena, California 91125. Received January 7, 1977

Abstract: Formation of gas-phase Lewis acid-base adducts (CH<sub>3</sub>)<sub>n</sub> $F_{4-n}SiF^{-}$  (n = 0-2) in reactions of SF<sub>6</sub><sup>-</sup> and SF<sub>5</sub><sup>-</sup> with neutral fluoromethylsilanes are examined using trapped-anion ion cyclotron resonance spectroscopy. Fluoride transfer reactions observed in binary mixtures of the silanes and of silanes with borane Lewis acids  $R_3B$  ( $R = CH_3$ ,  $C_2H_5$ , *i*- $C_3H_7$ , F), in the presence of trace amounts of SF<sub>6</sub> as the fluoride source, establish the Lewis acidity order BF<sub>3</sub> > SiF<sub>4</sub> >  $(i-C_3H_7)_2FB > (i-C_3H_7)_2FB > (i-C_3H_7$  $C_{3}H_{7}B > (C_{2}H_{5})_{2}FB > (C_{2}H_{5})_{3}B > (CH_{3})_{2}FB > CH_{3}SiF_{3} > (CH_{3})_{3}B > (CH_{3})_{2}SiF_{2} > SF_{4} > (CH_{3})_{3}SiF$  in the gas phase for F<sup>-</sup> as reference base. Quantitative estimates of adduct bond dissociation energies  $D[(CH_3)_nF_{4-n}Si-F^-]$  (n = 0-2) and heats of formation of adducts  $(CH_3)_nF_{4-n}SiF^-$  are derived. Variations in adduct bond strengths are discussed in terms of the effects of methyl and fluorine substitution on silicon. Analogies are drawn to similar substituent effects observed in the isoelectronic neutral fluoromethylphosphoranes.

Electron-pair dative bond formation between acceptor species A, which possess low-lying vacant orbitals, and donors B, which have accessible lone pairs (phenomena most generally described by the Lewis theory of acid-base interactions<sup>2</sup>), encompass chemical behavior common to much of the periodic table. Among the more familiar Lewis acids are the group 3b acceptors (compounds of B, Al, Ga, etc.) and many metal cations (from groups 1a, 2a, and compounds of the transition metals).<sup>3,4</sup> Studies of dissociation equilibria (eq 1) and displacement reactions (eq 2),

$$AB \rightleftharpoons A + B \quad \Delta H \equiv D[A - B] \tag{1}$$

$$A_1B + A_2 \rightleftharpoons A_1 + A_2B \tag{2}$$

employing a common reference base B, have provided information on adduct bond dissociation energies and insight into

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relationships between molecular structure and chemical reactivity for a wide variety of polyatomic Lewis acids, both in solution and in the gas phase.<sup>3,4</sup>

By comparison, much less is known about Lewis acid properties of neutral group 4b acceptors  $R_4M$  (M = C, Sn, Ge, etc.), where formation of acid-base adducts requires coordinative expansion of nominally closed-shell (electron octet) systems. Under the influence of higher effective nuclear charge and with the availability of lower energy vacant d orbitals, the tendency for dative bonding is increased for the heavier members of the group (e.g., Ge, Sn, Pb).<sup>5</sup> For carbon systems, Dougherty has reported several anionic halide adducts  $\{CH_3XY^- \text{ (where } X, Y = Cl, Br, I), {}^6H_nCl_{4-n}CCl^- \text{ (}n =$ (0-3),<sup>7</sup> and  $R_3CBr_2^-$  (where R = H, alkyl)<sup>8</sup> in the gas phase using high-pressure mass spectrometry. Only in the case of CCl<sub>5</sub><sup>-</sup>, however, is the involvement of pentacoordinate carbon without controversy. Yamdagni and Kebarle<sup>9</sup> have attributed the stability of the chloride adduct with chloroform to strong hydrogen bonding of the type  $[Cl_3C - H - Cl]^-$ . From studies of the temperature dependence of equilibria such as eq 1 where  $B = Cl^-$ , bond dissociation energies  $D[Cl_4C - Cl^-] = 14.2 \pm$  $0.7 \text{ kcal/mol}^7$  and  $D[Cl_3HC - Cl^-] = 15.2 \text{ kcal/mol}^9$  have been determined.

A number of theoretical calculations<sup>10-18</sup> have examined adducts involving pentacoordinate carbon and silicon, with the primary interest being in the investigation of potential energy surfaces for bimolecular nucleophilic substitution (S<sub>N</sub>2) reactions. Relevant to the present study are comparisons of the relative energies of separated reactants and transition states of the  $S_N 2$  surfaces (i.e., the reaction complexes corresponding to pentacoordinate adducts). Various calculations<sup>10-14</sup> show that for carbon and silicon systems, the most stable adduct geometries are of  $D_{3h}$  symmetry (trigonal bipyramidal). Recently, large basis set ab initio calculations by Baybutt<sup>10</sup> have compared the adducts H... $CH_3$ ... $H^-$ , F... $CH_3$ ... $F^-$ , H... SiH3...H<sup>-</sup>, and F...SiH3...F<sup>-</sup>. CH5<sup>-</sup> and CH3F2<sup>-</sup> were found to be less stable than the separated reactants by 61.2 and 2.1 kcal/mol, respectively, while SiH<sub>5</sub><sup>-</sup> and SiH<sub>3</sub>F<sub>2</sub><sup>-</sup> adducts were calculated to be more stable by 18.6 and 52.1 kcal/mol, respectively.<sup>10</sup> It was found that while d orbitals are not entirely responsible for the stability of the silicon adducts, their inclusion in the basis functions do increase the stabilities of  $SiH_5^-$  and  $SiH_3F_2^-$  substantially (by ~10 kcal/mol).<sup>10</sup>

A number of pentacoordinate silicon adducts have been experimentally observed. Pentacoordinate amine adducts (CH<sub>3</sub>)<sub>3</sub>NSiF<sub>4</sub>,<sup>19</sup> (CH<sub>3</sub>)<sub>3</sub>NSiHF<sub>3</sub>,<sup>20</sup> and (CH<sub>3</sub>)<sub>3</sub>NSi(CH<sub>3</sub>)- $F_3^{21}$  have been observed in the gas phase. From measurements of dissociation equilibria of these complexes it is found that adduct stability decreases sharply with replacement of F by H on silicon and even more so with replacement of F by CH<sub>3</sub>.<sup>22</sup> SiF<sub>5</sub><sup>-</sup> was first reported as a salt  $\{[(C_2H_5)_3P]_2PtC\}$ (CO) $+SiF_5^-$ , the unexpected product of heating C<sub>2</sub>F<sub>4</sub> and  $[(C_2H_5)_3P]_2$ PtHCl in a silica vessel.<sup>23</sup> NMR studies of SiF<sub>5</sub><sup>-</sup>,  $RSiF_4^-$ , and  $R'_2SiF_3^-$  species (R = alkyl, aryl; R' = aryl) indicate trigonal-bipyramidal structures below -60 °C in solvents of low polarity.<sup>24</sup> Recent gas-phase studies using ion cyclotron resonance spectroscopy (ICR) and high-pressure mass spectrometry (HPMS) have examined the formation of anions containing pentacoordinate silicon. MacNeil and Thynne<sup>25</sup> report the formation of SiF<sub>5</sub><sup>-</sup> by a rapid fluoride transfer reaction ( $k = 2.2 \times 10^{-10} \text{ cm}^3 \text{ mol}^{-1} \text{ s}^{-1}$ ) from SiF<sub>3</sub><sup>-</sup>, generated by electron impact, in SiF<sub>4</sub>. Dillard<sup>26</sup> has recently measured cross sections for anion transfer reactions

$$SF_6^- + (CH_3)_n F_{4-n} Si \rightarrow (CH_3)_n F_{4-n} SiF^- + SF_5 \quad (3)$$

(where n = 1-3) for reactant ion energies as low as 0.5 eV using HPMS. Reaction cross sections were observed to decrease rapidly with successive substitution of CH<sub>3</sub> for F on silicon; the fluoride adduct of (CH<sub>3</sub>)<sub>3</sub>SiF was barely detectable. McDaniel<sup>27</sup> has reported an ICR study of fluoride transfer reactions (analogous to process 2) among a variety of inorganic Lewis acids. The observed relative Lewis acidity order SF<sub>4</sub> < HCl < SiF<sub>4</sub> < BF<sub>3</sub> served to establish the limits<sup>27,28</sup> 54 ≤  $D[F_4Si-F^-] < 71$  kcal/mol in the gas phase.

Recent ICR studies from this laboratory<sup>29</sup> of fluoride transfer reactions (analogous to processes 2 and 3) in mixtures of trialkylboranes and BF<sub>3</sub> indicate that the fluoride affinities  $D[A-F^-]$  of acids R<sub>3</sub>B and R<sub>2</sub>FB (R = CH<sub>3</sub>, C<sub>2</sub>H<sub>5</sub>, *i*-C<sub>3</sub>H<sub>7</sub>) all lie intermediate between SF<sub>4</sub> and BF<sub>3</sub>. In the present report, we wish to describe results of trapped-anion ICR investigations of gas-phase fluoride transfer reactions occurring in the fluoromethylsilanes (CH<sub>3</sub>)<sub>n</sub>F<sub>4-n</sub>Si (n = 0-3), both alone and in binary mixtures, in the presence of SF<sub>6</sub> as the fluoride source. In addition, fluoride transfer reactions observed in mixtures of these silanes with the alkylboranes and  $BF_3$  afford quantitative estimates of silane Lewis acidities, for  $F^-$  as reference base.

## **Experimental Section**

All studies reported herein utilize a high-field ICR spectrometer (employing a 15-in. magnet system) constructed in the Caltech instrument shops. Details of the instrumentation and experimental techniques associated with ICR spectrometry are described elsewhere.<sup>30</sup> Gas mixtures utilized are prepared directly in the ICR cell by admission of appropriate sample components through separate variable leak valves in a parallel inlet manifold. Absolute gas pressures are determined using a Schulz-Phelps ionization gauge, adjacent to the ICR cell, calibrated separately for each component against an MKS Baratron capacitance manometer (Model 90H1-E).<sup>30c</sup> A linear calibration of Baratron pressure (absolute) vs. ionization gauge current affords pressure determinations over a range of  $10^{-7}$ - $10^{-4}$  Torr. Overall accuracy in pressure measurement for these studies is estimated to be  $\pm 20\%$ , and represents the major source of error in reported reaction rate constants. All measurements are performed at ambient temperature (~22 °C). Bimolecular reaction rate constants are determined with knowledge of neutral gas pressures from the limiting slopes of semilog plots of trapped-ion abundance vs. time and by considering product distributions where applicable.

 $(CH_3)_3B$  and  $(C_2H_5)_3B$  were purchased from Alfa Inorganics and SF<sub>6</sub>, SiF<sub>4</sub>, BF<sub>3</sub>, and SO<sub>2</sub> from Matheson. Samples of  $(CH_3)_3$ SiF,  $(CH_3)_2$ SiF<sub>2</sub>, and CH<sub>3</sub>SiF<sub>3</sub> were provided through the courtesy of Professor J. G. Dillard, and that of  $(i-C_3H_7)_3B$  from Professor A. H. Cowley. Noncondensable impurities are removed from all samples by multiple freeze-pump-thaw cycles at liquid nitrogen temperatures; mass spectral analyses showed no detectable impurities in the samples utilized.

In all studies reported here, SF<sub>6</sub> is utilized as the source of fluoride ion. SF<sub>6</sub><sup>-</sup> (~95%) and SF<sub>5</sub><sup>-</sup> (~5%) are generated from neutral SF<sub>6</sub>, typically present at ~10<sup>-8</sup> Torr pressure, by rapid attachment of near thermal energy electrons produced in the ICR trapping well by inelastic collisions with neutrals present during the 10-ms electron beam pulse.<sup>31-33</sup> In mixtures containing (CH<sub>3</sub>)<sub>3</sub>SiF, SO<sub>2</sub>F<sup>-</sup> (generated by fluoride transfer from SF<sub>6</sub><sup>-</sup> to SO<sub>2</sub><sup>27,28a</sup>) was also tried as a source of F<sup>-</sup>. The electron beam energy utilized is nominally 70 eV for emission currents of ~10<sup>-7</sup> A.

Data reported in tables and figures are normalized to monoisotopic abundances ( ${}^{12}C$ , 98.89%;  ${}^{11}B$ , 80.22%;  ${}^{28}Si$ , 92.21%;  ${}^{32}S$ , 95.0%). Typically, ion concentrations comprising <1% of the total are not included in the reported data.

#### Results

Observed ion-molecule reactions between  $SF_6^-$  and each of the silanes  $(CH_3)_n F_{4-n}Si (n = 0-3)$  are described below. Fluoride ion transfer reactions dominate the anion chemistry of these systems and ultimately yield stable pentacoordinate silane-fluoride adducts  $(CH_3)_n F_{4-n}SiF^- (n = 0-2)$ . Then reactions initiated by  $SF_6^-$  in binary mixtures of the silanes are examined to determine relative fluoride affinities (Lewis acidities) of the neutrals. Finally, in attempts to quantify the fluoride affinities of the silanes, studies of mixtures of the silanes with various borane Lewis acids  $R_3B$  (where  $R = CH_3$ ,  $C_2H_5$ , *i*- $C_3H_7$ , and F) are described. The gas-phase fluoride affinities of these boranes are available from recent studies<sup>29</sup> and provide reference points for quantitative comparisons. Experimentally determined reaction rate constants are summarized in Table I.

SF<sub>6</sub>/SiF<sub>4</sub>. In a sample of SiF<sub>4</sub> at  $9.7 \times 10^{-7}$  Torr pressure containing trace amounts of SF<sub>6</sub> (~10<sup>-8</sup> Torr), production of SiF<sub>5</sub><sup>-</sup> via the reaction

$$SF_6^- + SiF_4 \rightarrow SiF_5^- + SF_5 \tag{4}$$

involving fluoride transfer from  $SF_6^-$  is in agreement with previous reports.<sup>27,34</sup>  $SF_5^-$  produced by dissociative electron capture in  $SF_6$  also generates  $SiF_5^-$  via the fluoride transfer reaction

$$SF_5^- + SiF_4 \rightarrow SiF_5^- + SF_4 \tag{5}$$

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System	Reaction	No. <sup>a</sup>	Rate constant <sup>b</sup>	Thermochemical implications
SF./SiF.	$SF_{c}^{-} + SiF_{c} \rightarrow SiF_{c}^{-} + SF_{c}$	4	4.2	$D[SiF, -F^-] > D[SF, -F^-]$
8, 4	$SF_e^+ + SiF_A \rightarrow SiF_e^+ + SF_A$	5	6.8	$D[SiF_4 - F^-] > D[SF_4 - F^-]$
SF <sub>4</sub> /CH <sub>3</sub> SiF <sub>3</sub>	$SF_{e}^{-} + CH_{3}SiF_{3} \rightarrow CH_{3}SiF_{4}^{-} + SF_{5}$	6	1.5	$D[(CH_3)F_3Si-F^-] > D[SF_5-F^-]$
	$SF_{\epsilon}^{-} + CH_{3}SiF_{3} \rightarrow CH_{3}SiF_{4}^{-} + SF_{4}$	7	2.6	$D[(CH_3)F_3Si-F^-] > D[SF_4-F^-]$
SF <sub>6</sub> /(CH <sub>3</sub> ) <sub>2</sub> SiF <sub>2</sub>	90% (CH <sub>3</sub> ) <sub>2</sub> SiF <sub>3</sub> <sup>-+</sup> SF <sub>5</sub>	8	1.3d	$D[(CH_3)_2F_2Si-F^2] > D[SF_5-F]$
	$\frac{SF_6 + (CH_3)_2 SIF_2}{10\%} SF_5 + \begin{cases} HF + (CH_3)F_2 CH_2 \\ or \\ CH_2 F + (CH_2)F_2 Si \end{cases}$	9	0.1d	$\Delta H_{\mathbf{f}}[(\mathrm{CH}_3)\mathrm{F}_2\mathrm{SiCH}_2] \leq -157.1,$ $\Delta H = -3.5^f$
	$SF_{c}^{-+} (CH_{a})_{a}SiF_{a} \rightarrow (CH_{a})_{a}SiF_{a}^{-+} SF_{a}$	10	0.3	$D[(CH_{3}),F_{3}Si] > D[SF_{4}-F^{-}]$
SF <sub>4</sub> /(CH <sub>2</sub> ) <sub>2</sub> SiF	$SF_{4}^{-}$ + (CH <sub>4</sub> ) <sub>2</sub> SiF $\#$ (CH <sub>4</sub> ) <sub>2</sub> SiF <sub>4</sub> <sup>-</sup> + SF <sub>4</sub>	С	< 0.01	$D[(CH_3),FSi-F^{-}] > D[SF,-F^{-}]$
0, (- 3, 3 -	$SF_{e}^{-}$ + (CH <sub>2</sub> ) <sub>2</sub> SiF <sub>2</sub> <sup>+</sup> + (CH <sub>2</sub> ) <sub>2</sub> SiF <sub>2</sub> <sup>-</sup> + SF <sub>e</sub>	С	< 0.01	$D[(CH_3)_3FSi-F^{-}] < D[SF_4-F^{-}]$
SF <sub>6</sub> /(CH <sub>3</sub> ) <sub>3</sub> SiF/SO <sub>2</sub>	$SO_3F^-$ + (CH <sub>3</sub> ) <sub>3</sub> SiF # (CH <sub>3</sub> ) <sub>3</sub> SiF <sub>2</sub> <sup>-</sup> + SO <sub>2</sub>	11c	< 0.01	$D[(CH_3)]$ FSi-F <sup>-</sup> ] < $D[SO_2$ -F <sup>-</sup> ]
	$SO_{2}F_{2}^{-}$ + (CH <sub>3</sub> ) <sub>2</sub> SiF # (CH <sub>3</sub> ) <sub>3</sub> SiF <sub>2</sub> <sup>-</sup> + SO <sub>2</sub> F	$12^c$	< 0.01	$D[(CH_3)_3FSi-F^-] < D[SO_3F-F^-]$
SF <sub>6</sub> /(CH <sub>3</sub> ) <sub>3</sub> SiF/(CH <sub>3</sub> ) <sub>3</sub> SiF <sub>2</sub>	$(CH_3)_3SiF_3^- + (CH_3)_3SiF \rightarrow (CH_3)_3SiF_3^- + (CH_3)_3SiF_3$	13c	< 0.01	$D[(CH_3)_3FSi-F^-] < D[(CH_3)_2F_3Si-F^-]$
SF <sub>6</sub> /(CH <sub>3</sub> ) <sub>2</sub> SiF <sub>2</sub> /CH <sub>3</sub> SiF <sub>3</sub>	$(CH_3)_2SiF_3^- + CH_3SiF_3 \rightarrow CH_3SiF_4^- + (CH_3)_2SiF_2^-$	14	2.2	$D[(CH_3)F_3Si-F^-] > D[(CH_3)_2F_2Si-F^-],$ $\Delta G < -2.6^g$
SF_/CH_SiF_/SiF_	$CH_3SiF_7 + SiF_7 \rightarrow SiF_7 + CH_3SiF_3$	15	~ 3 <sup>e</sup>	$D[F_{4}Si-F^{-}] > D[(CH_{2})F_{3}Si-F^{-}]$
SF <sub>6</sub> /(CH <sub>3</sub> ) <sub>3</sub> B/(CH <sub>3</sub> ) <sub>2</sub> SiF <sub>2</sub>	$(CH_3)_2SiF_3^- + (CH_3)_3B \rightarrow (CH_3)_3BF^- + (CH_3)_2SiF_2$	19	3.4	$D[(CH_3)_3B-F^-] > D[(CH_3)_2F_2Si-F^-],$ $\Delta G < -21.0^g$
	(CH <sub>3</sub> ) <sub>2</sub> BF <sub>2</sub> <sup>-+</sup> (CH <sub>3</sub> ) <sub>2</sub> SiF <sub>2</sub> # (CH <sub>3</sub> ) <sub>2</sub> SiF <sub>3</sub> <sup>-+</sup> (CH <sub>3</sub> ) <sub>2</sub> FB	с	< 0.01	$D[(CH_3)_2F_2Si-F^-] < D[(CH_3)_2FB-F^-]$
SF <sub>6</sub> /(CH <sub>3</sub> ) <sub>3</sub> B/CH <sub>3</sub> SiF <sub>3</sub>	$(CH_3)_3BF^- + CH_3SiF_3 \rightarrow CH_3SiF_4^- + (CH_3)_3B$	20	9.5	$D[(CH_3)F_3Si-F^-] > D[(CH_3)_3B-F^-]$
	$(CH_3)_2BF_3^- + CH_3SiF_3 \neq CH_3SiF_4^- + (CH_3)_2FB$	С	< 0.01	$D[(CH_3)F_3Si-F^-] < D[(CH_3)_2FB-F^-]$
SF <sub>6</sub> /(C <sub>2</sub> H <sub>5</sub> ) <sub>3</sub> B/CH <sub>3</sub> SiF <sub>3</sub>	$CH_3SII_4^- + (C_2H_5)_3B \rightleftharpoons (C_2H_5)_3BI^{-} + CH_3SII_3$	24	$K_{eq} = 2.3h$	$D[(C_2H_3)_3B-F^-] > D[(CH_3)F_3Si-F^-],$ $\Delta G = 0.5 \pm 0.1^g$
	(Calle)aBFa <sup>+</sup> + CHaSiFa #+ CHaSiFa <sup>+</sup> + (Calle)aFB	с	< 0.01	$D[(CH_2)F_3Si-F^-] < D[(C_2H_2)_2FB-F^-]$
SF <sub>4</sub> /(C <sub>4</sub> H <sub>4</sub> ) <sub>2</sub> B/SiF <sub>4</sub>	$(C_{2}H_{2})_{2}BF^{-} + SiF_{4} \rightarrow SiF_{5}^{-} + (C_{2}H_{5})_{2}B$	25	2.8	$D[F_{4}Si-F^{-}] > D[(C_{4}H_{4})_{3}B-F^{-}]$
0, ( = 2 = - 5, 3, 7 = 4	$(C_1H_1)_2BF_2^+ + SiF_4 \rightarrow SiF_5^+ + (C_2H_2)_2FB$	26	2.0	$D[F_{A}Si-F^{-}] > D[(C_{A}H_{A}),FB-F^{-}]$
$SF_6/(i-C_3H_7)_3B/SiF_4$	$(i \cdot \hat{C}_3 \hat{H}_2)_3 B \hat{F}^- + Si F_4 \rightarrow Si F_5^- + (i \cdot \hat{C}_3 \hat{H}_2)_3 B$	30	2.2	$D[F_4Si-F^-] > D[(i-C_3H_7)_3B-F^-],$ $\Delta G < -1.7^g$
	$(i-C_2H_2)_2BF_2^+ + SiF_4 \rightarrow SiF_5^- + (i-C_2H_2)_2B$	31	1.5	$D[F_3Si-F^-] > D[(i-C_3H_2)_2FB-F^-]$
SF <sub>4</sub> /BF <sub>3</sub> /CH <sub>3</sub> SiF <sub>3</sub>	$CH_3SiF_4 + BF_3 \rightarrow BF_4 + CH_3SiF_3$	34	2.1	$D[F_3B-F^-] > D[(CH_3)F_3Si-F^-]$
SF /BF /SiF	$\operatorname{SiF}_{a}^{-+} \operatorname{BF}_{a} \to \operatorname{BF}_{a}^{-+} \operatorname{SiF}_{a}$	35	~ 3 <sup>e</sup>	$D[F_B-F^-] > D[F_Si-F^-]$

<sup>*a*</sup> Reaction numbers refer to reactions specified in the text. <sup>*b*</sup> Rate constants are in units of  $\times 10^{-t_0}$  cm<sup>3</sup> molecule<sup>-t</sup> s<sup>-1</sup>, determined from the limiting slopes of reactant ion disappearance, considering product distributions where applicable. <sup>*c*</sup> Reactions not observed by double resonance, see text for discussions. <sup>*d*</sup> Total disappearance rate constant for reaction of SF<sub>6</sub><sup>-</sup> with (CH<sub>3</sub>)<sub>2</sub>SiF<sub>2</sub>; product distributions determined in cyclotron ejection experiments. <sup>*e*</sup> Rate constants estimated though quantitative data were not obtained, see text for discussion. <sup>*f*</sup> Calculated using data in Table 11. <sup>*g*</sup> Free energy changes in units of kcal/mol, determined as specified in the text. <sup>*h*</sup> Equilibrium constant for reaction 24, determined as specified in the text.



Figure 1. Temporal variation of trapped-anion abundances following a 10-ms 70-eV electron beam pulse in  $2.8 \times 10^{-6}$  Torr CH<sub>3</sub>SiF<sub>3</sub> in the presence of trace amounts of SF<sub>6</sub>.

 $SiF_5^-$  appears stable to further reaction under these conditions.

 $SF_6/CH_3SiF_3$ . The temporal variation of ion abundances initiated by the electron beam pulse in 2.8  $\times$  10<sup>-6</sup> Torr CH<sub>3</sub>SiF<sub>3</sub> in the presence of trace amounts of SF<sub>6</sub> is displayed in Figure 1. Fluoride transfer reactions

$$SF_6^- + CH_3SiF_3 \rightarrow CH_3SiF_4^- + SF_5$$
(6)

$$SF_5^- + CH_3SiF_3 \rightarrow CH_3SiF_4^- + SF_4 \tag{7}$$

yielding  $CH_3SiF_4^-$ , are detected by double resonance. In contrast to processes described below in the  $SF_6/(CH_3)_2SiF_2$  system,  $SF_5^-$  is not produced by reaction of  $SF_6^-$  with  $CH_3SiF_3$ .  $CH_3SiF_4^-$  produced by reactions 6 and 7 does not react further under the present conditions.

 $SF_6/(CH_3)_2SiF_2$ . Electron impact in a sample of  $(CH_3)_2SiF_2$ at  $1.6 \times 10^{-6}$  Torr containing trace amounts of  $SF_6$  results in the temporal variation of trapped anion abundances shown in Figure 2. The pentacoordinate  $(CH_3)_2SiF_3^-$  anion is formed by fluoride transfer reactions 8 and 10, analogous to processes

$$\stackrel{90\%}{\longrightarrow} (CH_3)_2 SiF_3^- + SF_5 \tag{8}$$

$$SF_{6}^{-} + (CH_{3})_{2}SiF_{2} - 10\% SF_{5}^{-} + \begin{cases} HF + (CH_{3})F_{2}SiCH_{2} \\ or (9) \\ CH_{3}F + CH_{3}SiF_{2} \end{cases}$$

$$SF_{5}^{-} + (CH_{3})_{2}SiF_{2} \rightarrow (CH_{3})_{2}SiF_{3}^{-} + SF_{4}$$
 (10)

observed in SiF<sub>4</sub> and CH<sub>3</sub>SiF<sub>3</sub>. In addition, double resonance indicates reaction 9 to be responsible for the initial increase in SF<sub>5</sub><sup>-</sup> shown in Figure 2. Generation of SF<sub>5</sub><sup>-</sup> has previously been reported in reactions of SF<sub>6</sub><sup>-</sup> with a variety of molecules (e.g., HX, where X = Cl, Br, I;<sup>28a</sup> R<sub>3</sub>B, where R = CH<sub>3</sub>, C<sub>2</sub>H<sub>5</sub>, *i*-C<sub>3</sub>H<sub>7</sub>;<sup>29,35</sup> HCO<sub>2</sub>H, CH<sub>3</sub>CO<sub>2</sub>H, H<sub>2</sub>S<sup>33b</sup>). The neutral products in reaction 9 remain uncertain. Formation of CH<sub>3</sub>F and CH<sub>3</sub>SiF<sub>2</sub> radical is calculated to be ~3.5 kcal/mol exothermic.<sup>36</sup> (CH<sub>3</sub>)<sub>2</sub>SiF<sub>3</sub><sup>-</sup> appears stable to further reaction under these conditions.

SF<sub>6</sub>/(CH<sub>3</sub>)<sub>3</sub>SiF and SF<sub>6</sub>/SO<sub>2</sub>/(CH<sub>3</sub>)<sub>3</sub>SiF. Under a variety of experimental conditions, no silicon-containing anions are produced in either SF<sub>6</sub>/(CH<sub>3</sub>)<sub>3</sub>SiF or SF<sub>6</sub>/SO<sub>2</sub>/(CH<sub>3</sub>)<sub>3</sub>SiF mixtures. Specifically, no pentacoordinate (CH<sub>3</sub>)<sub>3</sub>SiF<sub>2</sub><sup>-</sup> is observed. These gas mixtures were examined by variation of pressure (up to  $\sim 10^{-4}$  Torr) and of ion trapping time at constant pressure ( $\sim 10^{-6}$  Torr (CH<sub>3</sub>)<sub>3</sub>SiF). In the SF<sub>6</sub>/



Figure 2. Temporal variation of trapped-anion abundances following a 10-ms 70-eV electron beam pulse in  $1.6 \times 10^{-6}$  Torr (CH<sub>3</sub>)<sub>2</sub>SiF<sub>2</sub> in the presence of trace amounts of SF<sub>6</sub>.

 $(CH_3)_3SiF$  mixture,  $SF_6^-$  (~95%) and  $SF_5^-$  (~5%), generated by electron capture processes in  $SF_6$ , remain completely unreactive as a function of pressure and trapping time. Generation of  $SF_5^-$  by processes analogous to eq 9 are not observed. In the presence of  $SO_2$ ,  $SF_6^-$  and  $SF_5^-$  react to generate  $SO_2F^-$  and  $SO_2F_2^{-28a}$  The latter anion reacts further with  $SO_2$  by fluoride transfer to yield  $SO_2F^-$  as the final stable product ion.  $SO_2F^-$  and  $SO_2F_2^-$  do not react with (CH<sub>3</sub>)<sub>3</sub>SiF. In particular, fluoride transfer reactions 11 and 12 are not observed.

$$SO_2F^- + (CH_3)_3SiF * (CH_3)_3SiF_2^- + SO_2$$
 (11)

$$SO_2F_2^- + (CH_3)_3SiF \leftrightarrow (CH_3)_3SiF_2^- + SO_2F$$
 (12)

 $SF_6/(CH_3)_3SiF_2$  from  $(CH_3)_2SiF_2$ . In further attempts to generate  $(CH_3)_3SiF_2^-$  from  $(CH_3)_3SiF$ , anion reactions in mixtures of  $SF_6$ ,  $(CH_3)_3SiF$ , and  $(CH_3)_2SiF_2$  are examined as a function of pressure and trapping time. The only silicon-containing anion detected is  $(CH_3)_2SiF_3^-$  produced by reactions 8–10 as described above. Notably, fluoride transfer from  $(CH_3)_2SiF_3^-$  to  $(CH_3)_3SiF$  (reaction 13) is not observed.

$$(CH_3)_2SiF_3^- + (CH_3)_3SiF \leftrightarrow (CH_3)_3SiF_2^- + (CH_3)_2SiF_2$$
(13)

 $SF_6/(CH_3)_2SiF_2/CH_3SiF_3$ . The variations in trapped-anion abundances initiated by the electron beam pulse in a 4.7:1 mixture of  $(CH_3)_2SiF_2$  and  $CH_3SiF_3$  (in the presence of traces of  $SF_6$ ) at 3.4  $\times$  10<sup>-6</sup> Torr total pressure are displayed in Figure 3. In addition to reactions 6–10 described above, the fluoride transfer reaction

$$(CH_3)_2SiF_3^- + CH_3SiF_3 \rightarrow CH_3SiF_4^- + (CH_3)_2SiF_2$$
(14)

accounts for the disappearance of  $(CH_3)_2SiF_3^-$  at long times in Figure 3.  $CH_3SiF_4^-$  is unreactive in this mixture.

 $SF_6/CH_3SiF_3/SiF_4$ . In an ~1:1 mixture of CH<sub>3</sub>SiF<sub>4</sub> and SiF<sub>4</sub> at ~2 × 10<sup>-6</sup> Torr, CH<sub>3</sub>SiF<sub>3</sub><sup>-</sup> and SiF<sub>5</sub><sup>-</sup> are produced initially by reactions 4-7 described above. Difficulties in maintaining constant pressure in the mixture<sup>37</sup> precluded detailed examination of the kinetics, but is apparent that the fluoride transfer reaction 15

$$CH_3SiF_4^- + SiF_4 \rightarrow SiF_5^- + CH_3SiF_3$$
(15)



Figure 3. Temporal variation of trapped-anion abundances following a 10-ms 70-eV electron beam pulse in a 4.7:1 mixture of  $(CH_3)_2SiF_2$  and  $CH_3SiF_3$  at  $3.4 \times 10^{-6}$  Torr in the presence of trace amounts of SF<sub>6</sub>.



**Figure 4.** Temporal variation of trapped-anion abundances following a 10-ms 70-eV electron beam pulse in a 7.5:1 mixture of  $(CH_3)_2SiF_2$  and  $(CH_3)_3B$  at  $2.2 \times 10^{-6}$  Torr in the presence of trace amounts of SF<sub>6</sub>.

(confirmed by double resonance) proceeds rapidly to completion.

 $SF_6/(CH_3)_3B/(CH_3)_2SiF_2$ . The temporal variation in anion abundances initiated by the electron beam pulse in a 7.5:1 mixture of  $(CH_3)_2SiF_2$  and  $(CH_3)_3B$  at a constant pressure of  $2.2 \times 10^{-6}$  Torr in the presence of traces of  $SF_6$  is shown in Figure 4. Reactions 16-18

$$SF_{6}^{-} + (CH_{3})_{3}B$$
 (16)

$$(CH_3)_2 BF_2 + SF_4 + CH_3$$
 (17)

$$SF_{5}^{-} + (CH_{3})_{3}B \rightarrow (CH_{3})_{3}BF^{-} + SF_{4}$$
 (18)

have been previously reported in  $SF_6/(CH_3)_3B$  mixtures.<sup>29,35</sup> In addition to reactions 8–10 described above, fluoride transfer from  $(CH_3)_2SiF_3^-$  to  $(CH_3)_3B$ 

$$(CH_3)_2SiF_3^- + B(CH_3)_3 \rightarrow (CH_3)_3BF^- + (CH_3)_2SiF_2$$
(19)

is detected by double resonance, accounting for the decay of  $(CH_3)_2SiF_3^-$  at long times in Figure 4. Both  $(CH_3)_3BF^-$  and  $(CH_3)_2BF_2^-$  are stable to further reaction in this mixture.



Figure 5. Temporal variation of trapped-anion abundances following a 10-ms 70-eV electron beam pulse in a 4.4:1 mixture of  $(CH_3)_3B$  and  $CH_3SiF_3$  at 5.4 × 10<sup>-7</sup> Torr in the presence of trace amounts of SF<sub>6</sub>.

 $SF_6/(CH_3)_3B/CH_3SiF_3$ . Figure 5 shows the time evolution of anion concentrations following the electron beam pulse in a 4.4:1 mixture of  $(CH_3)_3B$  and  $CH_3SiF_3$  at a total pressure of  $5.4 \times 10^{-7}$  Torr in the presence of trace amounts of SF<sub>6</sub>. In addition to reactions 6 and 7 described above and reactions 16-18 previously reported in the SF<sub>6</sub>/B(CH<sub>3</sub>)<sub>3</sub> system,<sup>29,35</sup> the fluoride transfer reaction

$$(CH_3)_3BF^- + CH_3SiF_3 \rightarrow CH_3SiF_4^- + B(CH_3)_3 \quad (20)$$

is observed in the  $SF_6/(CH_3)_3B/CH_3SiF_3$  mixture. (CH<sub>3</sub>)<sub>2</sub>BF<sub>2</sub><sup>-</sup> does not react with CH<sub>3</sub>SiF<sub>3</sub>. CH<sub>3</sub>SiF<sub>4</sub><sup>-</sup> is also stable to further reaction in the mixture.

 $SF_6/B(C_2H_5)_3/CH_3SiF_3$ . In a 1:1 mixture of  $(C_2H_5)_3B$  and  $CH_3SiF_3$  at a constant pressure of 7.9  $\times 10^{-7}$  Torr containing traces of SF<sub>6</sub>, the temporal variation of anion abundances depicted in Figure 6 is initiated by the electron beam pulse. Boron-containing anions,  $(C_2H_5)_3BF^-$  and  $(C_2H_5)_2BF_2^-$ , are initially produced via reactions 21–23, previously reported from

$$SF_{6}^{-} + (C_{2}H_{5})_{3}B \xrightarrow{} SF_{5}^{-} + HF + (C_{2}H_{5})_{2}BC_{2}H_{4} (21)$$
  
(C\_{2}H\_{5})\_{2}BF\_{2}^{-} + SF\_{4} + C\_{2}H\_{5} (22)

$$SF_{5}^{-} + (C_{2}H_{5})_{3}B \rightarrow (C_{2}H_{5})_{3}BF^{-} + SF_{4}$$
 (23)

studies of SF<sub>6</sub>/(C<sub>2</sub>H<sub>5</sub>)<sub>3</sub>B mixtures.<sup>29</sup> CH<sub>3</sub>SiF<sub>4</sub><sup>-</sup> is produced, at short reaction times in Figure 6, by processes 6 and 7 described above. For trapping times beyond ~500 ms in Figure 6, the relative concentrations of  $(C_2H_5)_3BF^-$  and CH<sub>3</sub>SiF<sub>4</sub><sup>-</sup> approach a constant ratio of 2.30 ± 0.05. Double resonance indicates that the reaction

$$CH_3SiF_4^- + (C_2H_5)_3B \rightleftharpoons (C_2H_5)_3BF^- + CH_3SiF_3 \quad (24)$$

proceeds in both forward and reverse directions. These results suggest that a fluoride transfer equilibrium is established between  $(C_2H_5)_3B$  and  $CH_3SiF_3$  with the balance lying preferentially to the right in reaction 24. The equilibrium constant  $K_{eq} = 2.3$  is determined,<sup>38</sup> corresponding to a free energy change  $\Delta G = -0.5 \pm 0.1$  kcal/mol. With the conditions used,  $(C_2H_5)_2BF_2^-$  is not observed to react further with CH<sub>3</sub>SiF<sub>3</sub>.

 $SF_6/(C_2H_5)_3B/SiF_4$ . In trapped-ion experiments on a 5.4:1 mixture of  $(C_2H_5)_3B$  and  $SiF_4$  at  $1.2 \times 10^{-6}$  Torr in the presence of trace amounts of  $SF_6$ , ions  $SiF_5^-$ ,  $(C_2H_5)_3BF^-$ , and  $(C_2H_5)_2BF_2^-$  are formed initially via processes 4, 5, and 21–23 described above for the individual components. At long reaction times  $SiF_5^-$  abundance continues to increase at the

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Figure 6. Temporal variation of trapped-anion abundances following a 10-ms 70-eV electron beam pulse in a 1:1 mixture of  $(C_2H_5)_3B$  and  $CH_3SiF_3$  at 7.9 × 10<sup>-7</sup> Torr in the presence of trace amounts of SF<sub>6</sub>.

expense of  $(C_2H_5)_3BF^-$  and  $(C_2H_5)_2BF_2^-$ . Double resonance indicates the occurrence of the rapid fluoride transfer reactions

$$(C_2H_5)_3BF^- + SiF_4 \rightarrow SiF_5^- + (C_2H_5)_3B$$
 (25)

$$(C_2H_5)_2BF_2^- + SiF_4 \rightarrow SiF_5^- + (C_2H_5)_2FB$$
 (26)

 $SiF_5^-$  eventually comprises ~100% of the ion abundance and is not observed to react further under the present conditions.

 $SF_6/B(i-C_3H_7)_3/SiF_4$ . The temporal variation of ion concentrations following the electron beam pulse in a 3.5:1 mixture of  $B(i-C_3H_7)_3$  and  $SiF_4$  at  $9.4 \times 10^{-7}$  Torr total pressure (in the presence of trace  $SF_6$ ) is displayed in Figure 7. Boroncontaining anions are formed initially by reactions 27-29, previously observed in  $SF_6/(i-C_3H_7)_3B$  mixtures.<sup>29</sup>

$$SF_6^{-} + B(i-C_3H_7)_3 - SF_5^{-} + HF + (i-C_3H_7)_2BC_3H_6$$
 (27)  
(*i*-C\_3H\_7)\_3 - (*i*-C\_3H\_7)\_3BF\_7^{-} + SF\_4 + *i*-C\_3H\_7(28)

$$SF_5^- + B(i-C_3H_7)_3 \rightarrow (i-C_3H_7)_3BF^- + SF_4$$
 (29)

In addition to processes 4 and 5 described above,  $SiF_5^-$  is generated by the fluoride transfer reactions

$$(i-C_{3}H_{7})_{3}BF^{-} + SiF_{4} \rightarrow SiF_{5}^{-} + B(i-C_{3}H_{7})_{3}$$
 (30)

$$(i-C_{3}H_{7})_{2}BF_{2}^{-} + SiF_{4} \rightarrow SiF_{5}^{-} + (i-C_{3}H_{7})_{2}FB$$
 (31)

and is not observed to react further under the present conditions.

 $SF_6/BF_3/CH_3SiF_3$ . In trapped-ion experiments on a 1.1:1 mixture of  $CH_3SiF_3$  and  $BF_3$  at  $1.2 \times 10^{-6}$  Torr pressure containing trace amounts of  $SF_6$ ,  $CH_3SiF_4^-$  is produced initially via reactions 6 and 7 described above and  $BF_4^-$  is generated by previously reported processes 32 and  $33.^{27,29,33a}BF_4^$ is produced by fluoride transfer from  $CH_3SiF_4^-$  (reaction 34). No evidence is obtained for the reverse of reaction 34, and  $BF_4^-$  appears stable to further reaction under the conditions utilized.

$$SF_6^- + BF_3 \rightarrow BF_4^- + SF_5 \tag{32}$$

$$SF_5^- + BF_3 \rightarrow BF_4^- + SF_4 \tag{33}$$

$$CH_3SiF_4^- + BF_3 \rightarrow BF_4^- + CH_3SiF_3 \qquad (34)$$

SF<sub>6</sub>/BF<sub>3</sub>/SiF<sub>4</sub>. In an  $\sim$ 1:1 mixture of SiF<sub>4</sub> and BF<sub>3</sub> at  $\sim$ 1  $\times$  10<sup>-6</sup> Torr pressure in the presence of trace amounts of SF<sub>6</sub>,



**Figure 7.** Temporal variation of trapped-anion abundances following a 10-ms 70-eV electron beam pulse in a 3.5:1 mixture of  $(i-C_3H_7)_3B$  and SiF<sub>4</sub> at 9.4 × 10<sup>-7</sup> Torr in the presence of trace amounts of SF<sub>6</sub>.

fluoride transfer reactions 4, 5, 32, and 33 described above lead to the formation of  $SiF_5^-$  and  $BF_4^-$ . Although experimental difficulties in maintaining stable gas pressures in this mixture<sup>37</sup> inhibit detailed examination of the reaction kinetics, it is clear that fluoride transfer from  $SiF_5^-$  to  $BF_3$ 

$$\mathrm{SiF}_5^- + \mathrm{BF}_3 \to \mathrm{BF}_4^- + \mathrm{SiF}_4 \tag{35}$$

proceeds rapidly to completion. No evidence is obtained for the back reaction and  $BF_4^-$  does not appear to react further under the present conditions.

## Discussion

 $SF_6^-, SF_5^-/(CH_3)_n F_{4-n}Si$  (n = 0-3). Observations of pentacoordinate anions  $SiF_5^-$ ,  $CH_3SiF_4^-$ , and  $(CH_3)_2SiF_3^$ formed by fluoride transfer reactions, between the respective neutral silanes and  $SF_6^-$  and  $SF_5^-$  (Table I), are in agreement with previous studies.<sup>26</sup> However, under no conditions was fluoride transfer to  $(CH_3)_3SiF$  observed in the present work. The discrepancy between this result and the observations of Dillard<sup>26</sup> are not fully understood, although differences in the energy of reactants  $SF_6^-$  and  $SF_5^-$  between the two studies may be responsible. In trapped-ion ICR, inelastic collisions with neutral molecules during the long trapping times effectively thermalize the ions. Thus, reactions observed are assumed to be exothermic or thermoneutral for thermal energy reactants.

Reactions 5, 7, and 10 require that the fluoride affinities of  $(CH_3)_2SiF_2$ ,  $CH_3SiF_3$ , and  $SiF_4$  exceed ~54 kcal/mol, the value previously reported<sup>28a</sup> for  $D[SF_4-F^-]$ . Failure to detect  $(CH_3)_3SiF_2^-$  by reaction with  $SF_6^-$  implies that  $D[(CH_3)_3FSi-F^-] < D[SF_5-F^-] = 11 \pm 8 \text{ kcal/mol},^{28a}$  a drastic decrease in Lewis acidity of  $(CH_3)_3SiF$  as compared with the more highly fluorinated silanes. It is possible that fluoride transfer from  $SF_6^-$  to  $(CH_3)_3SiF$  is not observed due to kinetic rather than thermodynamic effects.<sup>28a</sup> The fluoride affinity of SO<sub>2</sub>, though not known precisely, is very near that of  $SF_4$ .<sup>27,28a</sup> Failure to observe  $(CH_3)_3SiF_2^-$  by reaction of  $SO_2F^-$  or  $SF_5^-$  requires that  $D[(CH_3)_3FSi-F^-]$  be <54 kcal/mol.

SF<sub>6</sub>/Silane Mixtures. Reactions 13–15 imply the order of Lewis acidities  $(CH_3)_3SiF < (CH_3)_2SiF_2 < CH_3SiF_3 < SiF_4$ . As previously observed in studies of anion transfer processes in borane Lewis acids,<sup>29,35</sup> alkyl substitution in place of fluorine  $\alpha$  to the acceptor center results in decreased acidity.



Figure 8. Schematic representation of Lewis acidities of neutral acceptors A using  $F^-$  ion as reference base (expressed as fluoride affinities  $D[A-F^-]$ ).

SF<sub>6</sub>/Silane–Borane Mixtures. The fluoride affinity of SiF<sub>4</sub> is known from previous studies to be below that of BF<sub>3</sub> (71 kcal/mol).<sup>27</sup> Quantification of the fluoride affinities of (CH<sub>3</sub>)<sub>2</sub>SiF<sub>2</sub>, CH<sub>3</sub>SiF<sub>3</sub>, and SiF<sub>4</sub>, within the 17-kcal range bracketed by SF<sub>4</sub> and BF<sub>3</sub>, is obtained from the preferred directions of fluoride transfer reactions with borane Lewis acids previously shown to span this same fluoride affinity range.<sup>29</sup> Taken collectively with previous results,<sup>29</sup> these reactions (Table I) establish the fluoride affinity order (CH<sub>3</sub>)<sub>3</sub>SiF < SF<sub>4</sub> < (CH<sub>3</sub>)<sub>2</sub>SiF<sub>2</sub> < (CH<sub>3</sub>)<sub>3</sub>B < CH<sub>3</sub>SiF<sub>3</sub> < (CH<sub>3</sub>)<sub>2</sub>FB < (C<sub>2</sub>H<sub>5</sub>)<sub>3</sub>B < (C<sub>2</sub>H<sub>5</sub>)<sub>2</sub>FB < (*i*-C<sub>3</sub>H<sub>7</sub>)<sub>3</sub>B < (*i*-C<sub>3</sub>H<sub>7</sub>)<sub>2</sub>FB < SiF<sub>4</sub> < BF<sub>3</sub> in the gas phase. Only in the case of reaction 24 in the SF<sub>6</sub>/(C<sub>2</sub>H<sub>5</sub>)<sub>3</sub>B/CH<sub>3</sub>SiF<sub>3</sub> system is evidence of an equilibrium obtained.

Thermochemical Considerations. The observed  $K_{eq} = 2.3$  favoring fluoride bound to  $(C_2H_5)_3B$  requires that a free energy change of ~0.5 kcal/mol accompany reaction 24. Trapped-ion ICR techniques are generally able to provide accurate determinations of similar anion transfer equilibria and associated free energy changes up to values of ~3 kcal/mol. Larger free energy changes yield equilibrium constants (and forward and reverse rate constants) exceeding the dynamic range of the technique.

Considering the relative order of fluoride affinities stated above, it is noteworthy that reactions 14, 19, and 30 proceed only in the forward direction. This conclusion is apparent from data in Figures 3, 4, and 7 and the failure to detect the reverse reactions by double resonance. The ratios of reactant and product ions at long times and ratios of neutral acid pressures place lower limits on  $K_{eq}$  of >83.2, >34.9, and >18.9 for reactions 14, 19, and 30, respectively, corresponding to free energy changes of <-2.6, <-2.1, and <-1.7 kcal/mol. Similar limits apply to reactions 15 and 30.

A quantity more relevant to discussion of adduct bond energies  $D[A-F^-]$  is the enthalpy change  $\Delta H$ , which is related to the free energy change  $\Delta G = \Delta H - T\Delta S = -RT$ ln  $K_{eq}$ . The present ICR instrumentation is limited to measurements at ambient temperatures, precluding experimental determination of  $\Delta H$  from variations of  $K_{eq}$  and thus  $\Delta G$  with temperature. Within reasonable assumptions, the statistical mechanical formalism of Searles and Kebarle<sup>39</sup> may be used to estimate that  $\Delta S$  for reaction 24 is negligible. Thus  $\Delta H \cong$ -0.5 kcal/mol for fluoride transfer from CH<sub>3</sub>SiF<sub>4</sub><sup>-</sup> to

Table II. Thermochemical Quantities<sup>a</sup> Utilized in the Calculations

А	$\Delta H_{\rm f}({\rm A})$	$D[A-F^-]$
SF <sub>4</sub>	$-183 \pm 6^{b}$	$54 \pm 12^{b}$
SF <sub>5</sub>	$-232 \pm 4^{b}$	$11 \pm 8^{b}$
$SF_5^-$	$-298 \pm 6$	
$SF_6^-$	$-304.4 \pm 3.5^{b}$	
CH₃F	-55.9°	
HF	$-64.9 \pm 0.3^{b}$	
CH <sub>3</sub> SiF <sub>2</sub>	$-166.0^{d}$	
(CH <sub>3</sub> ) <sub>3</sub> SiF	$-126.0^{d}$	
$(CH_3)_2SiF_2$	$-212.0^{d}$	
CH <sub>3</sub> SiF <sub>3</sub>	$-296.0^{d}$	
SiF4	$-386.0^{d}$	<71 <sup>f</sup>
(CH <sub>3</sub> ) <sub>3</sub> B	-29.3 <sup>e</sup>	58.5°
$(CH_3)_2FB$	$\leq -61.9^{e}$	61.8 <sup>e</sup>
$(C_2H_5)_3B$	-36.0 <sup>e</sup>	62.0 <i>e</i>
$(C_2H_5)_2FB$	$\leq -58.1^{e}$	64.0 <i>°</i>
( <i>i</i> -C <sub>3</sub> H <sub>7</sub> ) <sub>3</sub> B	-56.3e	65.0 <i>°</i>
$(i-C_{3}H_{7})_{2}FB$	$\leq -67.5^{e}$	66.5 <sup>e</sup>
BF <sub>3</sub>	$-271.7^{e}$	71 <sup>ſ</sup>
$BF_4^-$	$-404.0^{e}$	
F <sup>-</sup>	$-61.3 \pm 0.3^{b}$	

<sup>a</sup> All data are in units of kcal/mol at 298 K. <sup>b</sup> Reference 28a. <sup>c</sup> M. K. Murphy and J. L. Beauchamp, J. Am. Chem. Soc., **99**, 2085 (1977). <sup>d</sup> J. A. Kerr and D. M. Timlin, Int. J. Chem. Kinet., **3**, 427 (1971). <sup>e</sup> Reference 29. <sup>f</sup> Reference 27.

 
 Table III. Thermochemical Quantities<sup>a</sup> Describing lons and Neutrals of Silicon

Acid, A	$D[A-F^-]^b$	$\Delta H_{\rm f}[{\rm A}]^c$	$\Delta H_{\rm f}[{\rm AF}^-]^d$
SiF <sub>4</sub>	68.0	-386.0	-515.3¢
CH <sub>3</sub> SiF <sub>3</sub>	61.5	-296.0	-418.5/
(CH <sub>3</sub> ) <sub>2</sub> SiF <sub>2</sub>	55.5	-212.0	-328.5¢
(CH <sub>3</sub> ) <sub>3</sub> SiF	<54	-126.0	>-241.0 <sup>h</sup>

<sup>a</sup> All data are in units of kcal/mol at 298 K. <sup>b</sup> Bond dissociation energies determined as specified in the text. <sup>c</sup> Heats of formation of the silanes from Table 11. <sup>d</sup> Calculated using data in Table 11 and this table. <sup>e</sup> Calculated from  $\Delta H_{f}[SiF_{5}^{-}] = \Delta H_{f}[SiF_{4}] + \Delta H_{f^{-}}[BF_{4}^{-}] - \Delta H_{f}[BF_{3}] - \Delta H_{r}$ , where  $\Delta H_{r} = -3$  kcal/mol for reaction 35. <sup>f</sup> Calculated from  $\Delta H_{f}[CH_{3}SiF_{4}^{-}] = \Delta H_{f}[CH_{3}SiF_{3}] + \Delta H_{f}[(C_{2}H_{5})_{3}BF^{-}] - \Delta H_{f}[(C_{2}H_{5})_{3}B] - \Delta H_{r}$ , where  $\Delta H_{r} = -0.5$ kcal/mol for reaction 24. <sup>g</sup> Calculated from  $\Delta H_{f}[(CH_{3})_{2}SiF_{3}^{-}] = \Delta H_{f}[(CH_{3})_{3}BF^{-}] + \Delta H_{f}[(CH_{3})_{2}SiF_{2}] - \Delta H_{f}[(CH_{3})_{3}B] - \Delta H_{r}$ , where  $\Delta H_{r} = -3$  kcal/mol for reaction 19. <sup>h</sup> Estimated from  $\Delta H_{f}[(CH_{3})_{3}SiF_{2}^{-}] > \Delta H_{f}[SF_{5}^{-}] + \Delta H_{f}[(CH_{3})_{3}SiF] - \Delta H_{f}[SF_{4}]$ from failure to observe F<sup>-</sup> transfer from SF\_{5}^{-} to (CH<sub>3</sub>)<sub>3</sub>SiF.

### $(C_2H_5)_3B_1$

Evaluation of the present results along with the results of the previous study of the boranes,<sup>29</sup> assuming a minimum separation of  $\sim$ 3 kcal/mol in cases where no reverse reactions were evidenced, affords a quantitative scale of fluoride affinities, which is fully consistent with all available data, as displayed schematically in Figure 8. Using available thermochemical data (Table II) and estimates of 68, 61.5, and 55.5 kcal/mol for the fluoride affinities of SiF<sub>4</sub>, CH<sub>3</sub>SiF<sub>3</sub>, and  $(CH_3)_2SiF_2$ , heats of formation for the silane-fluoride Lewis adduct anions can be derived (Table III). Taking -3, -0.5, and -3 kcal/mol for the enthalpy changes for reactions 19, 24, and 35, respectively, yields estimates of  $\Delta H_{\rm f}((\rm CH_3)_2SiF_3^-)$ = -328.5,  $\Delta H_{\rm f}({\rm CH}_3{\rm SiF}_4^-) = -418.5$ , and  $\Delta H_{\rm f}({\rm SiF}_5^-) =$ -515.3 kcal/mol. Failure to observe (CH<sub>3</sub>)<sub>3</sub>SiF<sub>2</sub><sup>-</sup> by reaction of  $(CH_3)_3SiF$  with  $SF_5^-$  or  $SO_2F^-$  requires that  $\Delta H_f((CH_3)_3SiF_2^-)$  exceed -241.0 kcal/mol. Thermochemical data describing the neutral silane Lewis acids and fluoride adducts are summarized in Table III.

Substituent Effects on Silane Lewis Acidity. From the data in Figure 8 and Table III, which quantitatively describe the gas-phase Lewis acidities of the fluoromethylsilanes with fluoride ion as the reference base, it is apparent that the intrinsic acceptor strengths (measured as fluoride affinities,  $D[A-F^{-}]$ ) of borane and silane Lewis acids are quite comparable in absolute magnitude. The effects of fluorine and alkyl substituents on boron and silicon follow similar trends, namely that alkyl groups lower the acidity relative to fluorine substituents. Alkyl groups appear to more strongly destabilize the silane-fluoride relative to the borane-fluoride adducts (Figure 8). In contrast to the present results, adduct strengths of these same silanes toward  $(CH_3)_3N$  as reference base have been previously shown to be much lower than those for borane Lewis acids.<sup>22b</sup> Measurements of gas-phase dissociation equilibria for processes such as eq 1 where  $B = (CH_3)_3N$  indicate a Lewis acidity order  $(CH_3)_3B\gg SiF_4\gg CH_3SiF_3.^{19-21,22b,40}$  The steric requirements of the bulky amine base clearly have a marked effect on the stability of adducts with the silanes. Attenuation of steric effects are expected for adducts involving the smaller monatomic fluoride ion as reference base.

Upon replacement of F by CH<sub>3</sub>, the fluoride affinity of CH<sub>3</sub>SiF<sub>3</sub> is decreased by  $\sim$ 6.5 kcal/mol relative to that of SiF<sub>4</sub>. Similarly,  $(CH_3)_2SiF_2$  binds  $F^- \sim 6$  kcal/mol less strongly than does CH<sub>3</sub>SiF<sub>3</sub>. While the actual value of the fluoride affinity of (CH<sub>3</sub>)<sub>3</sub>SiF is yet to be determined, the failure to observe F<sup>-</sup> transfer from  $SF_6^{-} \{D[SF_5 - F^-] = 11 \pm 1\}$ 8 kcal/mol<sup>28a</sup> implies a dramatic decrease in acceptor strength of  $\sim 40$  kcal/mol resulting from substitution of a third CH<sub>3</sub> for F on silicon.

Methyl substituent effects on the stability of pentacoordinate fluoromethylsilyl anions observed in the present work have interesting analogies in the isoelectronic neutral methylfluorophosphorane series  $PF_5$ ,  $CH_3PF_4$ ,  $(CH_3)_2PF_3$ , and  $(CH_3)_3PF_2$ .<sup>41,42</sup> The species  $(CH_3)_4PF$  is unknown and it has been proposed that this least stable member of the phosphorane series would better be described as an ionic phosphorium salt  $[(CH_3)_4P]^+F^{-.42}$  By a variety of spectroscopic techniques, it has been conclusively demonstrated that the phosphoranes have trigonal-bipyramidal geometry with the less electronegative organic groups preferentially occupying equatorial sights.<sup>41</sup> Apical metal-substituent bond lengths are substantially longer than bonds at equatorial positions. Low-temperature <sup>1</sup>H and <sup>19</sup>F NMR spectra of SiF<sub>5</sub><sup>-</sup>, CH<sub>3</sub>SiF<sub>4</sub><sup>-</sup>, and  $(C_6H_5)SiF_4^-$  in low polarity solvents<sup>24</sup> indicate that these fluorosilicate anions also have trigonal-bipyramidal structures with the organic groups occupying equatorial sights. This positional preference, governed primarily by differences in substituent electronegativity, has previously been termed "the polarity rule" and is known to be general to a variety of trigonal-bipyramidal complexes.5,41

Analogous to the present observations of decreasing silane-fluoride bond strengths accompanying successive substitution of CH<sub>3</sub> for F, axial P-F bonds are known to lengthen and weaken in going from PF5 to CH3PF4, (CH3)2PF3, and (CH<sub>3</sub>)<sub>3</sub>PF<sub>2</sub>.<sup>41,42</sup> Under the influence of the electrostatic field imposed by a trigonal-bipyramidal array of electronegative fluorine substituents, the 3d<sub>2</sub> orbital contracts sufficiently to make its inclusion in the bonding energetically favorable.<sup>42,43</sup> Successive replacement of F by the more electropositive CH<sub>3</sub> would result then in a concomitant decrease in the net positive character of the central atom and lead to a gradual withdrawal of the d orbitals from the bonding scheme. Ultimately the five-coordinate trigonal-bipyramidal structure would cease to be energetically attractive.<sup>42</sup> In the pentacoordinate silicon anions, the  $3d_{z^2}$  orbital is probably much more diffuse than in the neutral phosphorus compounds. Thus, abrupt decrease in stability of the adducts occurs upon substitution of just three CH<sub>3</sub> groups on the central atom.

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